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ACCEPTED MANUSCRIPT

Multilayer and functionally gradient films of plasma polymers intended as

compatible interlayers for hybrid materials

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Abstract

Complex film structures, such as multilayer and gradient films, were deposited using

tetravinylsilane monomer by plasma-enhanced chemical vapor deposition. The optical and

mechanical properties of the deposited film were controlled by the effective power if pulsed

plasma was used. Functionally nanostructured films with zigzag, step, and gradient

distributions of optical and mechanical properties across the film were constructed in one

deposition using time-dependent effective power. The optical and mechanical properties of the

deposited films were investigated by spectroscopic ellipsometry and cyclic nanoindentation

measurements, respectively. Analyses confirmed expected patterns of optical properties across

the film structures. Controlled deposition of tailored films is a new technological step for the

creative design and application of complex film structures in smart materials and devices.

Keywords: multilayer, gradient film, plasma polymerization, ellipsometry, nanoindentation

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